

CORRECTION

Correction: Occurrence of Diverse Antimicrobial Resistance Determinants in Genetically Unrelated Biocide Tolerant *Klebsiella pneumoniae*

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In Fig 6, images B (i) and B (ii) are incorrectly displayed. Please see the corrected Fig 6 here.



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Fig 6. Oxidative stress and bioflim formating assay in *K. pneumoniae* **strains.** (A) Diagram showing the zone of inhibition in different strains due to the different concentration of H_2O_2 . In this study 0%, 0.1%, 1%, 3%, and 10% of H_2O_2 were used as oxidative stress inducing agent. The diagram represents the mean of three independent experiments. (B) Biofilm formation by the *K. pneumoniae* isolates are shown here: i) tubes showing stained biofilm rings in few representative isolates ii) graphical presentation of biofilm formation among the isolates is shown as the ratio of OD_{570nm} and OD_{600nm} . The bar graph represents the mean of three independent experiments.

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Reference

1. Mondal A, Venkataramaiah M, Rajamohan G, Srinivasan VB (2016) Occurrence of Diverse Antimicrobial Resistance Determinants in Genetically Unrelated Biocide Tolerant *Klebsiella pneumoniae*. PLoS ONE 11(11): e0166730. doi:10.1371/journal.pone.0166730 PMID: 27870879